

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant	:	Shimbori, H.
Appl. No.	:	10/561,760
Filed	:	December 21, 2005
For	:	RESIN FOR POSITIVE RESIST COMPOSITION, AND POSITIVE RESIST COMPOSITION USING THE SAME, LAMINATE AND METHOD FOR FORMING RESIST PATTERN
Examiner	:	Lee, Sin J.
Group Art Unit	:	1752

**AMENDMENT AND RESPONSE TO FINAL OFFICE ACTION****Mail Stop AF**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

In response to the final Office Action mailed **March 18, 2008**, please consider the following amendments and remarks.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 5 of this paper.